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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/808,374 Group Art Unit: 1796
Filing Date: March 25, 2004 Examiner: Irina S. Zemel
Applicant: Yi Yeol LYU et al.
Title: COMPOSITION FOR FORMING DIELECTRIC FILM AND
METHO FOR FORMING DIELECTRIC FILM OR
PATTERN USING THE COMPOSITION
Attorney Docket: 6661-000041/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop Amendment

April 8, 2009

OK TO ENTER: /IZ/

AMENDMENT UNDER 37 C.F.R. §1.116

04/15/2009

Madam:

In response to the Final Office Action mailed January 13, 2009, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

Amendments to the Claims begin on page 2 of this Amendment.

Remarks begin on page 9 of this Amendment.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	11	-	22	=	0
Independent	1	-	3	=	0